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JEP/AB
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q60118

Kazuyoshi MIZUTANI, et al.

Appln. No.: 09/615,708

Group Art Unit: 1752

Confirmation No.: 5086

Examiner: C. HAMILTON

Filed: July 13, 2000

For: BOTTOM ANTI-REFLECTIVE COATING MATERIAL COMPOSITION AND
METHOD FOR FORMING RESIST PATTERN USING THE SAME

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TECHNOLOGY CENTER 1700

AMENDMENT UNDER 37 C.F.R. § 1.111

Commissioner for Patents
Washington, D.C. 20231

Sir:

This Amendment is submitted in response to the Office Action dated September 6, 2002. A Petition for a two-month extension of time is being concurrently filed, making a response due on or before February 6, 2003. Please amend the above-identified application as follows:

IN THE CLAIMS:

Please enter the following amended claims:

12. (Twice Amended) A bottom anti-reflective coating material composition comprising a polymer light absorbent having at least one group represented by the following formula (X), (XI), (XII), (XIII), (XIV) or (XV) on the side chain:

X
Saw
CO